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Amendments to the Claims

Please cancel Claims 19-21, 23, and 25-43. Please amend Claims 1-3 and 5. Please add new Claims 48-67. The Claim Listing below will replace all prior versions of the claims in the application:

Claim Listing

- 1. (Currently amended) A purge gas mixture supply system, comprising:
 - a purge gas source;
 - a water source; and
 - a purge gas mixture generator comprising a moisturizer configured to add moisture to a purge gas, wherein said moisturizer comprises a first region containing a purge gas flow and a second region containing water wherein the first and second regions are separated by a membrane contactorgas permeable membrane that is substantially resistant to liquid intrusion.
- (Currently amended) The supply system of Claim 1, wherein the membrane contactor is comprised of a thermoplastic polymer that is gas permeable and substantially resistant to liquid intrusion.
- 3. (Currently amended) The supply system of Claim 1, wherein the membrane contactor is comprised of a perfluorinated polymer that is gas permeable and substantially resistant to liquid intrusion.
- 4. (Original) The supply system of Claim 3, wherein the perfluorinated polymer is polytetrafluoroethylene.
- (Currently amended) The supply system of Claim 1, wherein the membrane contactor
 forms a hollow fiber that is gas permeable and substantially resistant to liquid intrusion

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and wherein one of the first and second regions is within the fiber and the other of the first and second regions is outside the fiber.

- 6. (Original) The supply system of Claim 5, wherein the moisturizer comprises:
 - a bundle of a plurality of gas-permeable hollow fiber membranes having a
 first end and a second end, said membranes having an outer surface and an
 inner surface, said inner surface comprising one of the first and second
 regions;
 - b) each end of said bundle ported with a liquid tight seal forming an end structure with a surrounding housing wherein the fiber ends are open to fluid flow;
 - said housing having an inner wall and an outer wall, wherein the inner wall defines the other of the first and second regions between the inner wall and the hollow fiber membranes;
 - said housing having a purge gas inlet connected to the purge gas source and a purge gas mixture outlet; and
 - e) said housing having a water inlet connected to the water source and a water outlet, wherein either the purge gas inlet is connected to the first end of the bundle and the purge gas mixture outlet is connected to the second end of the bundle or the water inlet is connected to the first end of the bundle and the water outlet is connected to the second end of the bundle,

and wherein said purge gas mixture comprises at least one purge gas and the moisture.

- 7. (Original) A purge gas mixture supply system, comprising:
 - a purge gas source;
 - a water source; and
 - a purge gas mixture generator comprising a moisturizer configured to add moisture to a purge gas, wherein said moisturizer comprises:
 - a) a bundle of a plurality of perfluorinated gas-permeable thermoplastic hollow fiber membranes having a first end and a second end, said

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- membranes having an outer surface and an inner surface, said inner surface comprising a lumen;
- b) each end of said bundle potted with a liquid tight perfluorinated thermoplastic seal forming a unitary end structure with a surrounding perfluorinated thermoplastic housing wherein the fiber ends are open to fluid flow;
- said housing having an inner wall and an outer wall, wherein the inner wall defines a fluid flow volume between the inner wall and the hollow fiber membranes;
- said housing having a purge gas inlet connected to the purge gas source and a purge gas mixture outlet; and
- e) said housing having a water inlet connected to the water source and a water outlet, wherein either the purge gas inlet is connected to the first end of the bundle and the purge gas mixture outlet is connected to the second end of the bundle or the water inlet is connected to the first end of the bundle and the water outlet is connected to the second end of the bundle,

and wherein said purge gas mixture comprises at least one purge gas and the moisture.

- 8. (Original) The supply system of Claim 7, further comprising a heating device for the water.
- (Original) The supply system of Claim 7, wherein the purge gas source comprises a
 purifier device.
- 10. (Original) The supply system of Claim 9, wherein the purifier device is regenerable.
- (Original) The supply system of Claim 10, wherein the purge gas source comprises two purifier devices and wherein the purifier devices are connected in parallel.

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- 12. (Original) The supply system of Claim 7, wherein the hollow fiber membranes are selected from the group consisting of:
 - hollow fiber membranes having a porous skinned inner surface, a porous outer surface and a porous support structure between;
 - b) hollow fiber membranes having a non-porous skinned inner surface, a porous outer surface and a porous support structure between;
 - hollow fiber membranes having a porous skinned outer surface, a porous inner surface and a porous support structure between; and
 - hollow fiber membranes having a non-porous skinned outer surface, a
 porous inner surface and a porous support structure between.
- 13. (Original) The supply system of Claim 12, wherein the hollow fiber membrane outer diameter is about 350 microns to about 1450 microns.
- 14. (Original) The supply system of Claim 12, wherein the hollow fiber membranes are hollow fiber membranes having a porous skinned inner surface, a porous outer surface and a porous support structure between; or hollow fiber membranes having a porous skinned outer surface, a porous inner surface and a porous support structure between; and the porous skinned surface pores are from about 0.001 microns to about 0.005 microns in diameter.
- 15. (Original) The supply system of Claim 7, wherein the first and second ends of the bundle are potted with a liquid tight perfluorinated thermoplastic seal forming a single unitary end structure comprising both the first and second ends with a surrounding perfluorinated thermoplastic housing wherein the fibers of the ends are separately open to fluid flow.
- 16. (Original) The supply system of Claim 7, wherein said supply system is capable of operation at a purge gas flow rate of at least about 30 standard liters per minute and a temperature of at least about 90°C.

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- 17. (Original) The supply system of Claim 7, wherein the purge gas mixture generator is heated for a sufficient length of time at a temperature sufficient to substantially remove compounds that volatilize at temperatures of about 100°C or less.
- 18. (Original) A method of humidifying a purge gas, comprising passing the purge gas through a moisturizer for a period sufficient to humidify the purge gas, wherein the moisturizer comprises a first region containing a purge gas flow and a second region containing water wherein the first and second regions are separated by a gas-permeable membrane that is substantially resistant to liquid intrusion.

19 through 21. (Canceled)

- (Original) The method of Claim 18, wherein the membrane forms a hollow fiber and wherein one of the first and second regions is within the fiber and the other of the first and second regions is outside the fiber.
- 23. (Canceled)
- 24. (Original) A method of humidifying a purge gas, comprising passing the purge gas through a moisturizer for a period sufficient to humidify the purge gas, wherein the moisturizer comprises:
 - a bundle of a plurality of perfluorinated thermoplastic hollow fiber membranes
 having a first end and a second end, said membranes having an outer surface and
 an inner surface, said inner surface comprising a lumen;
 - b) each end of said bundle potted with a liquid tight perfluorinated thermoplastic seal forming a unitary end structure with a surrounding perfluorinated thermoplastic housing wherein the fiber ends are open to fluid flow;
 - c) said housing having an inner wall and an outer wall, wherein the inner wall defines a fluid flow volume between the inner wall and the hollow fiber membranes;

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- d) said housing having a purge gas inlet connected to a purge gas source and a purge gas outlet; and
- e) said housing having a water inlet connected to a water source and a water outlet, wherein either the purge gas inlet is connected to the first end of the bundle and the purge gas outlet is connected to the second end of the bundle or the water inlet is connected to the first end of the bundle and the water outlet is connected to the second end of the bundle,

thereby obtaining a humidified purge gas.

25 through 43. (Canceled)

44. (Original) A lithographic projection apparatus, comprising:

an illuminator configured to provide a projection beam of radiation;

a support structure configured to support a patterning device, the patterning device configured to pattern the projection beam according to a desired pattern;

a substrate table configured to hold a substrate;

a projection system configured to project the patterned beam onto a target portion of the substrate; and

at least one purge gas supply system configured to provide a purge gas to at least part of the lithographic projection apparatus, the at least one purge gas supply system comprising:

a purge gas mixture generator comprising a moisturizer configured to add moisture to a purge gas, wherein the moisturizer comprises a first region containing a purge gas flow and a second region containing water wherein the first and second regions are separated by a gas-permeable membrane that is substantially resistant to liquid intrusion, the purge gas mixture generator configured to generate a purge gas mixture, which purge gas mixture comprises at least one purge gas and the moisture; and

a purge gas mixture outlet connected to the purge gas mixture generator configured to supply the purge gas mixture to the at least part of the lithographic projection apparatus.

45. (Original) A lithographic projection apparatus, comprising:

an illuminator configured to provide a projection beam of radiation;

a support structure configured to support a patterning device, the patterning device configured to pattern the projection beam according to a desired pattern;

a substrate table configured to hold a substrate;

a projection system configured to project the patterned beam onto a target portion of the substrate; and

at least one purge gas supply system configured to provide a purge gas to at least part of the lithographic projection apparatus, the at least one purge gas supply system comprising:

a purge gas mixture generator comprising a moisturizer configured to add moisture to a purge gas, wherein the moisturizer comprises:

- a) a bundle of a plurality of perfluorinated thermoplastic hollow fiber membranes having a first end and a second end, said membranes having an outer surface and an inner surface, said inner surface comprising a lumen;
- b) each end of said bundle potted with a liquid tight perfluorinated thermoplastic seal forming a unitary end structure with a surrounding perfluorinated thermoplastic housing wherein the fiber ends are open to fluid flow;
- said housing having an inner wall and an outer wall, wherein the inner wall defines a fluid flow volume between the inner wall and the hollow fiber membranes;
- d) said housing having a purge gas inlet connected to the purge gas source and a purge gas mixture outlet; and
- e) said housing having a water inlet connected to the water source and a water outlet, wherein either the purge gas inlet is connected to the first end of the bundle and the purge gas mixture outlet is connected to the second

end of the bundle or the water inlet is connected to the first end of the bundle and the water outlet is connected to the second end of the bundle, the purge gas mixture generator configured to generate a purge gas mixture, which purge gas mixture comprises at least one purge gas and the moisture; and

a purge gas mixture outlet connected to the purge gas mixture generator configured to supply the purge gas mixture to the at least part of the lithographic projection apparatus.

46. (Original) A method for providing a purge gas to at least part of a lithographic projection apparatus comprising:

an illuminator configured to provide a projection beam of radiation;

a support configured to support a patterning device, the patterning device configured to pattern the projection beam according to a desired pattern;

a substrate table configured to hold a substrate; and

a projection system configured to project the patterned beam onto a target portion of the substrate;

the method comprising:

generating a purge gas mixture which comprises at least one purge gas and moisture by adding moisture to a purge gas with a moisturizer, wherein the moisturizer comprises a first region containing a purge gas flow and a second region containing water wherein the first and second regions are separated by a gas-permeable membrane that is substantially resistant to liquid intrusion, and

supplying the purge gas mixture to at least a part of the lithographic projection apparatus.

47. (Original) A method for providing a purge gas to at least part of a lithographic projection apparatus comprising:

an illuminator configured to provide a projection beam of radiation;

a support configured to support a patterning device, the patterning device configured to pattern the projection beam according to a desired pattern;

of the substrate;

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a substrate table configured to hold a substrate; and a projection system configured to project the patterned beam onto a target portion

the method comprising:

generating a purge gas mixture which comprises at least one purge gas and moisture by adding moisture to a purge gas with a moisturizer, wherein the moisturizer comprises:

- a) a bundle of a plurality of perfluorinated thermoplastic hollow fiber membranes having a first end and a second end, said membranes having an outer surface and an inner surface, said inner surface comprising a lumen;
- b) each end of said bundle potted with a liquid tight perfluorinated thermoplastic seal forming a unitary end structure with a surrounding perfluorinated thermoplastic housing wherein the fiber ends are open to fluid flow;
- said housing having an inner wall and an outer wall, wherein the inner wall defines a fluid flow volume between the inner wall and the hollow fiber membranes;
- d) said housing having a purge gas inlet connected to a purge gas source and a purge gas mixture outlet; and
- e) said housing having a water inlet connected to a water source and a water outlet, wherein either the purge gas inlet is connected to the first end of the bundle and the purge gas mixture outlet is connected to the second end of the bundle or the water inlet is connected to the first end of the bundle and the water outlet is connected to the second end of the bundle, and

supplying the purge gas mixture to at least a part of the lithographic projection apparatus.

48. (New) The lithographic projection apparatus of Claim 44, wherein the membrane is comprised of a thermoplastic polymer.

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- 49. (New) The lithographic projection apparatus of Claim 44, wherein the membrane is comprised of a perfluorinated polymer.
- 50. (New) The lithographic projection apparatus of Claim 49, wherein the perfluorinated polymer is polytetrafluoroethylene.
- 51. (New) The lithographic projection apparatus of Claim 44, wherein the membrane forms a hollow fiber and wherein one of the first and second regions is within the fiber and the other of the first and second regions is outside the fiber.
- 52. (New) The lithographic projection apparatus of Claim 51, wherein the moisturizer comprises:
 - a bundle of a plurality of gas-permeable hollow fiber membranes having a first end and a second end, said membranes having an outer surface and an inner surface, said inner surface comprising one of the first and second regions;
 - b) each end of said bundle potted with a liquid right seal forming an end structure with a surrounding housing wherein the fiber ends are open to fluid flow;
 - said housing having an inner wall and an outer wall, wherein the inner
 wall defines the other of the first and second regions between the inner
 wall and the hollow fiber membranes;
 - d) said housing having a purge gas inlet connected to the purge gas source and a purge gas mixture outlet; and
 - e) said housing having a water inlet connected to the water source and a water outlet, wherein either the purge gas inlet is connected to the first end of the bundle and the purge gas mixture outlet is connected to the second end of the bundle or the water inlet is connected to the first end of the bundle and the water outlet is connected to the second end of the bundle,

and wherein said purge gas mixture comprises at least one purge gas and the moisture.

- 53. (New) The lithographic projection apparatus of Claim 45, further comprising a heating device for the water.
- 54. (New) The lithographic projection apparatus of Claim 45, wherein the purge gas source comprises a purifier device.
- 55. (New) The lithographic projection apparatus of Claim 54, wherein the purifier device is regenerable.
- 56. (New) The lithographic projection apparatus of Claim 55, wherein the purge gas source comprises two purifier devices and wherein the purifier devices are connected in parallel.
- 57. (New) The lithographic projection apparatus of Claim 45, wherein the hollow fiber membranes are selected from the group consisting of:
 - hollow fiber membranes having a porous skinned inner surface, a porous outer surface and a porous support structure between;
 - b) hollow fiber membranes having a non-porous skinned inner surface, a porous outer surface and a porous support structure between;
 - c) hollow fiber membranes having a porous skinned outer surface, a porous inner surface and a porous support structure between; and
 - d) hollow fiber membranes having a non-porous skinned outer surface, a porous inner surface and a porous support structure between.
- 58. (New) The lithographic projection apparatus of Claim 57, wherein the hollow fiber membrane outer diameter is about 350 microns to about 1450 microns.
- 59. (New) The lithographic projection apparatus of Claim 57, wherein the hollow fiber membranes are hollow fiber membranes having a porous skinned inner surface, a porous outer surface and a porous support structure between; or hollow fiber membranes having

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a porous skinned outer surface, a porous inner surface and a porous support structure between; and the porous skinned surface pores are from about 0.001 microns to about 0.005 microns in diameter.

- 60. (New) The lithographic projection apparatus of Claim 45, wherein the first and second ends of the bundle are ported with a liquid tight perfluorinated thermoplastic seal forming a single unitary end structure comprising both the first and second ends with a surrounding perfluorinated thermoplastic housing wherein the fibers of the ends are separately open to fluid flow.
- 61. (New) The lithographic projection apparatus of Claim 45, wherein said supply system is capable of operation at a purge gas flow rate of at least about 30 standard liters per minute and a temperature of at least about 90°C.
- 62. (New) The lithographic projection apparatus of Claim 45, wherein the purge gas mixture generator is heated for a sufficient length of time at a temperature sufficient to substantially remove compounds that volatilize at temperatures of about 100°C or less.
- 63. (New) The supply system of Claim 1, wherein the membrane contactor comprises a perfluorosulfonic acid polytetrafluoroethylene copolymer (Nafion®) membrane.
- 64. (New) The supply system of Claim 1, wherein the membrane contactor comprises a membrane comprising a substance suitable for use as a fuel cell humidifier.
- 65. (New) The supply system of Claim 64, wherein the membrane contactor comprises an ionomer.
- 66. (New) The supply system of Claim 65, wherein the membrane contactor comprises a sulfonated tetrafluoroethylene copolymer.

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67. (New) The supply system of Claim 66, wherein the membrane contactor comprises a perfluorosulfonic acid polytetrafluoroethylene copolymer (Nafion®) membrane.